

Plasmon modes of silver nanowire on a silica substrate

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Plasmon mode in a silver nanowire is theoretically studied when the nanowire is placed on or near a silica substrate. It is found that the substrate has much influence on the plasmon mode. For the nanowire on the substrate, the plasmon (hybrid) mode possesses not only a long propagation length but also an ultrasmall mode area. From the experimental point of view, this cavity-free structure holds a great potential to study a strong coherent interaction between the plasmon mode and single quantum system (for example, quantum dots) embedded in the substrate.

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The silver nanowire is a potential solution to key components in future ultra-compact electronic and photonic circuit [1–3] since it can confine the light in nanoscale beyond the diffraction limit. The strong confinement of light in a small area produces strong electric field intensity and dramatically changes the density of state nearby the metal surface. Therefore, the silver nanowire has been suggested to realize strong light-matter interaction, where the nanowire plays as the role of a resonator in cavity quantum electrodynamics (QED). When an optical emitter, e.g., a quantum dot (QD), is placed around the silver nanowire, its spontaneous emission can be significantly modified[4], known as the Purcell effect. As a result, single optical emitter coupling with plasmon modes of nanowire holds a great potential for broad-band cavity QED [4], single photon source [5], and sub-wavelength single photon transistor [6, 7] for quantum information science.

Theoretically, the plasmon mode in silver nanowire was studied as an ideal axis-symmetric mode [4], or still treated without the external influence even it was placed on a substrate [8–12]. However, in realistic applications, the silver nanowire is always necessary to be located on or near a substrate. For example, the nanowire on a substrate makes it convenient for manipulating assisted by the scanning near field optical microscope probe [8–16]. To the best of our knowledge, the influence on the plasmon mode from the substrate is still kept un-studied. Actually, the plasmon mode is very sensitive to the surrounding environment. In this Letter, we theoretically study the plasmon mode propagating along the silver nanowire near a substrate with a gap $g \geq 0$. In this silver-air-substrate structure, most of the mode energy is confined around the interface between the substrate and silver nanowire. It is very different from the nanowire simply embedded in air. The benefit of the nanowire on a substrate is that the large portion of energy in the substrate reduces the mode area by a factor of 5, without significant degradation of the propagation loss.

An infinite long silver nanowire with a diameter of d is near an infinite dielectric substrate with a gap of g . The cross section is shown Fig. 1(a). The surface plasmon mode propagates harmonically along the nanowire,

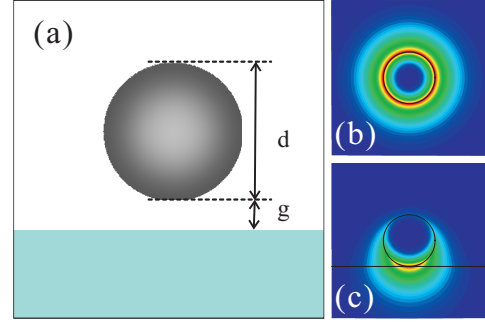


FIG. 1: (color online) (a) Schematic diagram of a silver nanowire near the silica substrate with a gap g . The diameter of nanowire is d . (b) and (c), the energy density distributions on the cross section of nanowire ($d = 100nm$) with $g = \infty, 0$, respectively.

and the electric field varies as $\exp(i\beta z - i\omega t)$, where the propagation constant $\beta = 2\pi n_{eff}/\lambda$ is a complex number because of the energy attenuation in the propagation. In this case, the Maxwell equation is reduced to two-dimensional cross section, which can be expressed as

$$[\nabla^2 + (n^2 - n_{eff}^2)(2\pi/\lambda)^2]\psi = 0, \quad (1)$$

where n and n_{eff} denote the refractive index of material and the effective index for the mode, respectively. The propagation length of the plasmon modes can be defined as

$$L = 1/2\text{Im}\{\beta\}. \quad (2)$$

Besides the propagation loss, another important parameter of the plasmon mode is effective mode area A , which can be defined by the ratio of a mode's total energy density per unit length and its peak energy density,

$$A = \int_{all} W(r) ds / \max\{W(r)\}, \quad (3)$$

where $W(r)$ represents the effective energy density with

$$W(r) = \frac{1}{2} \text{Re}\left\{\frac{d[\omega\varepsilon(r)]}{d\omega}\right\} |E(r)|^2 + \frac{1}{2}\mu_0 |H(r)|^2. \quad (4)$$

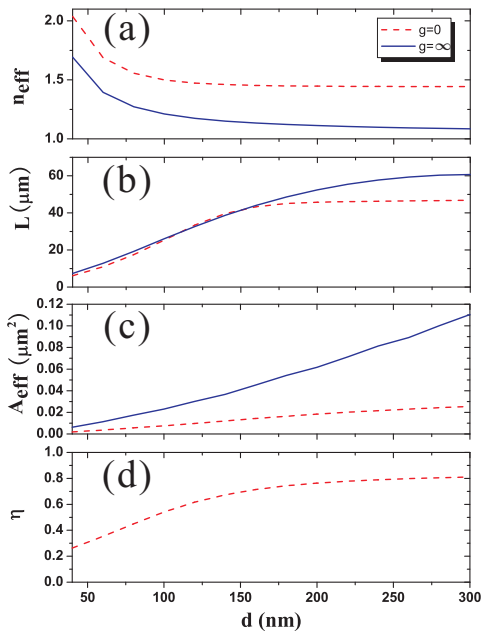


FIG. 2: (color online) Effective index (a), propagation loss (b), mode areas (c), and energy confinement in the substrate (d) of surface plasmon modes for the nanowire on the substrate (red dashed, $g = 0$) and in air (blue solid, $g = \infty$) versus the diameter of silver nanowire.

Here, $|E(r)|^2$ and $|H(r)|^2$ are the intensity of electric and magnetic fields, respectively. $\varepsilon(r)$ and μ_0 are the electric and vacuum magnetic permittivities.

To describe the impact from the substrate, we also define the confinement factor η as the portion of energy in substrate,

$$\eta = \int_{sub} W(r)ds / \int_{all} W(r)ds. \quad (5)$$

The confinement factor η can also quantify the interaction of SPP and substrate,

A finite element method is used to investigate the plasmon modes with a fixed wavelength at 637 nm. The energy distribution profiles of the plasmon modes in the nanowire are shown in Fig. 1(b) and (c), with $g = \infty, 0$, respectively. Here, $n_{air} = 1$ and $n_{sub} = 1.45$. It is not difficult to find a rotation symmetric field distribution when the nanowire is in air ($g = \infty$), while a strongly asymmetric field distribution is presented in the presence of the silica substrate ($g = 0$). Moreover, the maximum of the electric field is distributed in the substrate-nanowire gap. In other words, the substrate can significantly pull the mode field.

We first investigate the impact of the substrate on the plasmon modes for various nanowire sizes. Fig.2 shows the effective index (n_{eff}), propagation length (L), effective mode area (A_{eff}) and portion of energy (η) versus d . As a comparison, the ideal case without substrate ($g = \infty$) is also depicted. It is found that n_{eff} decreases with the increase of d , while L and A_{eff} shows

the opposite behaviors. This tradeoff between confinement and absorption loss is well known in the surface plasmon mode.

For the nanowire on silica substrate, comparing with the nanowire in air, n_{eff} is larger and A_{eff} is smaller with all d . These obvious differences come from the presence of large refractive index material near the metal nanowire. In addition, the mode area of the nanowire on silica substrate is only about 1/5 of that in air. To characterize the field pulling by the silica substrate, we present the confinement factor for $g = 0$ in Fig.2(d). The η increases with d to nearly 80% when $d = 200nm$.

In Fig.(2), A_{eff} simply increases with the increase of d . However, the other three parameters approach saturation values. In order to get a physic interpretation, we can approximately treat this hybrid system as the metal plane-substrate for large d . The analytical solution to Eq. (1) in the plane condition gives $n_{eff}^p = \sqrt{\epsilon_m \epsilon_s / (\epsilon_m + \epsilon_s)}$, where ϵ_m and ϵ_s is the electric permittivity of metal and substrate. So we have $n_{eff}^p = 1.537$, $L^p = 53\mu m$, and $\eta^p = 90\%$ in the plane limit.

Now, we turn to discuss the experimental condition, where the nanowire is near the substrate with a finite gap $g > 0$. This is a realistic case for many experiments because the substrate is not perfect smooth, or in specific experimental config, the nanowire is suspended in air[17]. By fixing the diameter $d = 100$ nm, we study the propagation loss and effective index (Fig.3) for different gaps between nanowire and substrate.

With the increase of gap g , n_{eff} monotonously decreases and gradually approaches the in-air case. This is because the influence of substrate becomes smaller when the nanowire departs from the substrate. When $g = 200$ nm, the substrate has a very minor effect on the plasmon mode of the silver. However, the dynamics of L is much more complicated than that of n_{eff} . When the silver nanowire moves away from the silica substrate, L increases first, then quickly drops to $2\mu m$. After that, it slowly increases, and finally approaches to $25\mu m$ [19]. We can divide the gap into three regimes: the near field, dissipation, and far field regimes, which correspond to different dynamics of L and different loss mechanisms.

(i) Near field regime. In this regime, we have $n_{eff} > n_{sub}$. Due to the phase mismatching, the dominant loss of the plasmon mode comes from the metal absorption. By increasing the gap, n_{eff} gradually decreases as the nanowire moves away from the substrate. A smaller n_{eff} indicates a smaller energy portion in the metal, so that the absorption loss is reduced with increasing g .

(ii) Dissipation Regime. When the gap further increases, n_{eff} may be smaller than n_{sub} . Meanwhile, the plasmon mode still has much energy in the substrate, as can be seen in the inset of Fig.3 ($g = 50$ nm). From Eq. (1), when $n_{eff} < n_{sub}$, the solutions are traveling waves in substrate as $\psi \propto \exp(i\sqrt{n_{sub}^2 - n_{eff}^2}x)$. The energy in traveling wave will dissipate into infinite space. Therefore, in this regime, the mode energy quickly dis-

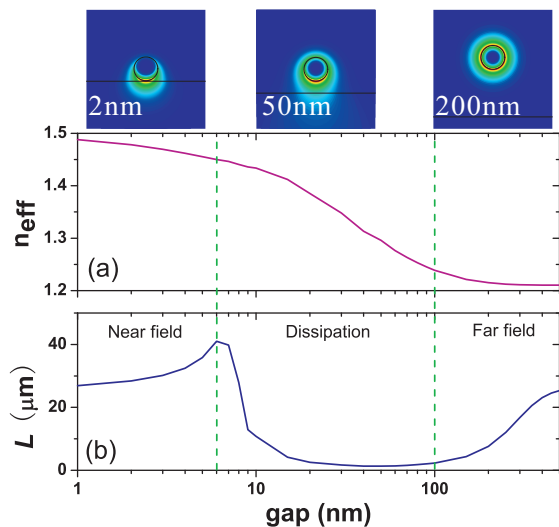


FIG. 3: (color online) Effective index (a) and propagation length (b) of the silver nanowire with $d=100$ nm versus the gap. Insets: mode field profiles of the surface plasmon modes with $g=2$ nm, 50 nm, 200 nm, respectively.

sipates by coupling to the dissipative traveling waves in the substrate. As a result, L has a sudden decrease.

(iii) The far field regime. When the nanowire further moves away from the substrate, for example, $g = 200$ nm, the coupling between the plasmon mode and the dissipative traveling modes in substrate becomes very weak as it is proportional to their field overlap. Thus, even $n_{eff} < n_{sub}$, the plasmon mode keeps almost unchanged by the substrate, and the mode profile approaches the case of $g = \infty$ (in the absence of the substrate). Therefore, L can be slowly recovered in this regime.

The above results indicate that the approximation by neglecting the substrate is not applicable in analyzing experimental results, where the energy confinement and propagation loss are significantly influenced by the substrate. When the gap is very small, most of the energy

is confined near nanowire-substrate interface and n_{eff} is large. It should be more efficient to coupling light to the surface plasmon mode through the substrate, especially for large d . The efficiently excitation of surface plasmon mode through substrate have been demonstrated recently[10, 11]. It is worth noticing that the propagation loss strongly depends on the gap. In a recent experiment, near field surface plasmon mode detection is demonstrated[17], where the silver nanowire is put on the Ge nanowire, with $g = 40$ nm, $d = 100$ nm and $\lambda = 600$ nm. From Fig. 3(b), it works in the dissipation regime with $L \approx 2\mu m$. For more efficiently detection, g should be larger than 200nm or smaller than 10nm .

In conclusion, we have numerically studied the mode profile, propagation loss and mode area of plasmon modes of a silver nanowire near the silica substrate. To reduce the propagation loss, our result suggests that the gap between silver nanowire and the substrate should be as small as possible. When the silver nanowire is attached to the substrate ($g = 0$), the propagation length is limited by metal absorption and the mode area is reduced by a factor of 5. In addition, for nanowire with $d = 200$ nm, the field energy portion of the plasmon mode in the substrate is as large as 80%, which is suitable for coupling to QDs or molecules embed in substrate. Accompanying with the scanning near field optical microscope, the silver nanowire can be precisely moved on the substrate, and selectively coupled to single QDs in substrate. This is potential for experimental realization of the single photon transistors, or coupling two distant QDs to generate entanglement for quantum information science.

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